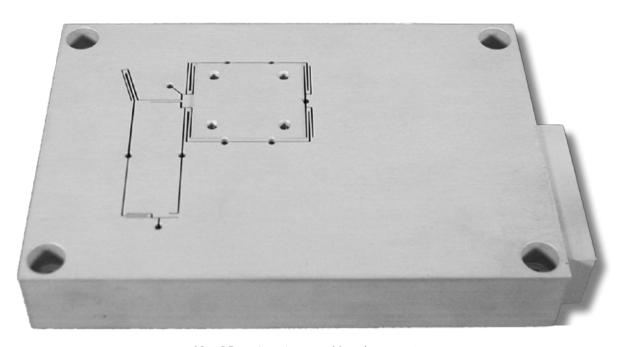
Features

- ▶ Long range single axis motion: 200 μm
- ▶ Less than 5 nm out of plane motion
- ▶ Low profile design
- pico sensor technology
- ▶ Closed loop control

Typical Applications

- ► Surface metrology
- ▶ Wafer scanning and alignment
- ▶ Optical alignment



Nano-LR200 (1-axis) constructed from aluminum.



Product Description

The Nano-LR200 is designed to provide long range, single axis translation with an absolute minimum of out-of-axis motion. The unique design of the Nano-LR200 produces less than 5 nm of out-of-plane motion; measured over the entire moving platform throughout the 200 µm range of motion. The Nano-LR200 sets the highest level of single axis precision and positioning performance. Internal position sensors utilizing proprietary picp technology provide absolute, repeatable posi-

tion measurement with sub-nanometer accuracy under closed loop control. The Nano-LR200 is ideally suited for applications that require extreme parallelism, such as metrology, AFM and MEMS.



Technical Specifications

Range of motion (X)	200 μm
Resolution	0.4 nm
Resonant Frequency	500 Hz ±20%
Resonant Frequency (100g load)	200 Hz ±20%
Stiffness	0.2 N/μm
θ_{roll} , θ_{pitch} (typical)	≤0.3 µrad
θ_{yaw} (typical)	
Recommended max. load (horizontal)*.	
Recommended max. load (vertical)*	0.2 kg
Body Material	Al
Controller	Nano-Drive®

^{*} Larger load requirements should be discussed with our engineering staff.

